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Influence of Oxidation on Electrical Properties of Compacted Cu Nanopowders

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Abstract

The phase composition and electrical transport properties of Cu powder obtained by electric spark dispersion and the pellets manufactured from this powder were studied by X-ray phase analysis and electric resistance measurements. The compacted powders were annealed in pure Ar atmosphere. It was shown that electrical resistance of the compacted Cu specimens essentially depends on the annealing temperature. In particular, the electrical resistance of the pellet after annealing at 873 K decreases on heating at low temperatures (semiconducting mechanism). As the temperature is increased, semiconducting behavior of resistivity is altered for metallic one. This change of conductivity type is ascribed to formation of metallic oxide and modification of its content during annealing.

Keywords: Electrical spark dispersion, Highly dispersed Cu nanopowders, X-ray diffraction analysis, Electric resistance

Background

The Cu-based Heusler alloys with restricted solubility are prospective materials for spintronic applications [1–3]. Nanopowders of the Cu-13.1 % Mn-12.6 % Al alloy were obtained by electrical spark dispersion (ESD) in different media including ethanol, gas, and water [4]. Electric conductivity of compacted powders (pellets) produced in ethanol and gas and annealed at 1073 K was found to be characteristic of semiconductors increasing with temperature in contrast to as-cast alloys, which demonstrate metallic-type conductivity.

Detailed analysis of all the results obtained led to conclusion that the type of conductivity is conditioned by formation of copper and manganese oxides in the process of preparation. The effect of copper oxide on electric conductivity is suggested to employ for controllable oxidization of pure copper to govern its conductivity. Thus, the aim of this study can be designated as determination of effect of phase content on electric conductivity of compacted copper powders prepared by successive procedures of electric spark dispersion, compacting, and annealing in argon atmosphere.

Methods

The subjects of this investigation were highly dispersed powder (nanopowder) and compacted specimens of Cu. They were prepared from high purity Cu (99.99 %). Highly dispersed powder was produced by electrical spark dispersion in distilled water; specimens were made by pressing powder [5]. After ESD, powder particles were collected from operating fluid. First, they have been dried in air at room temperature and then at temperature of 200 °C for 1 h in drying oven to remove moisture. Next, powder has been compacted at room temperature, and finally, some of compacted specimens were annealed at 873 and 1073 K for 30 min in argon environment. X-ray diffraction measurements were carried out using diffractometer DRON –3.0 with cobalt anode. Diffraction patterns were analyzed by comparison of lines with maximum intensity corresponding to different crystalline phases. The size of coherently scattering domains (CSD) was calculated using the Scherrer equation [6].

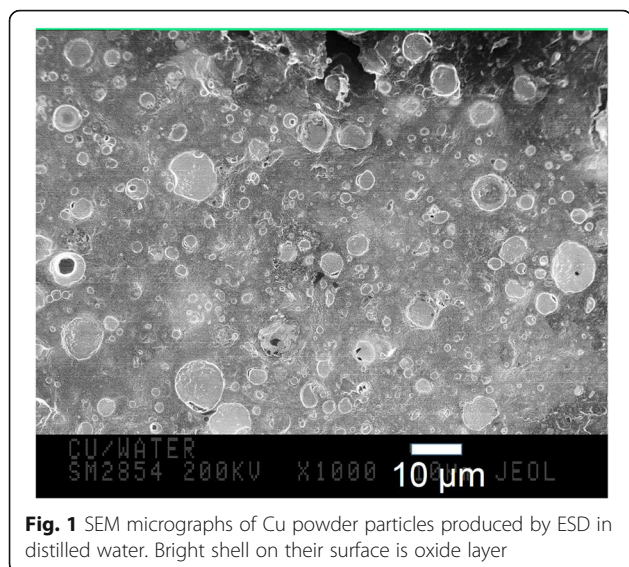
Results and Discussion

The image of highly dispersed powder particles obtained by SEM is shown in Fig. 1. The particle-size distribution determined from this micrograph indicates that size (average diameter) of Cu particles ranges from 0.25 to 14 μm. Particles of 0.5 ÷ 7 μm are almost spherical. The part of the smallest particles having dimension smaller

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than 1 μm forms conglomerates. Furthermore, presence of globular particles of larger than 0.5 μm implies active agglomeration processes occurring most likely while drying. Notice that most of particles shown in Fig. 1 are coated with light-colored oxide shells, which is consistent with the X-ray analysis data concerning presence of oxides.

The results of X-ray diffraction for Cu powder after ESD in distilled water, for as-compacted specimen, and for the specimens annealed at temperatures of 873 and 1073 K in gaseous argon are shown in Fig. 2 and Table 1. These data indicate that the initial powder and the pellet after compacting contained a great deal of copper oxide Cu_2O . Its amount was up to 38 % in the powder and 28 % in the pellet (Table 1). It is accounted for strong reaction

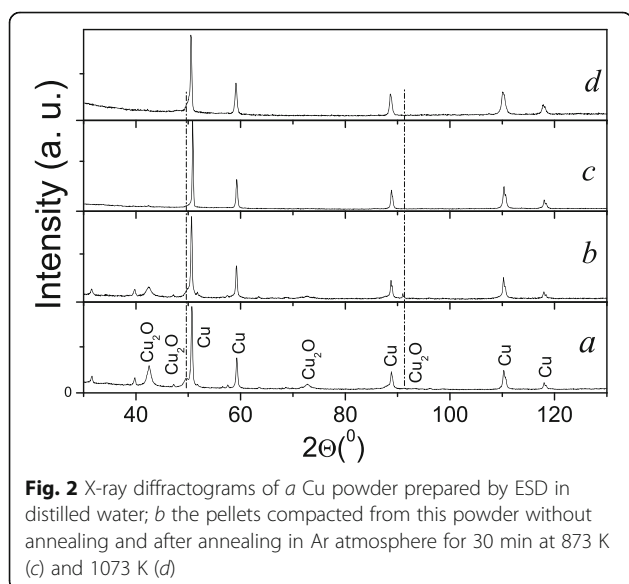
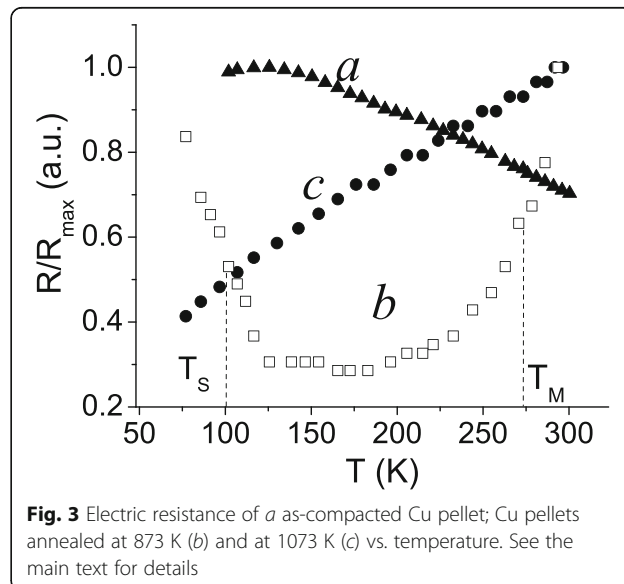


Table 1 Phase content and sizes of CSD (*D*) for as-received powder and pellets

Specimen	Constituent phases	Phase content, %	<i>D</i> , nm
Powder, after ESD	Cu	60	150
	Cu_2O	40	15
Pellet, after compacting	Cu	70	170
	Cu_2O	30	15
Pellet, after annealing at 873 K for 30 min	Cu	98	>500
	Cu_2O	2	130
Pellet, after annealing at 1073 K for 30 min	Cu	100	>500
	Cu_2O	–	

between the Cu and the O atoms during ESD to form Cu_2O . But annealing at 873 K led to decrease of Cu_2O down to 2 % (Fig. 2c, Table 1). Furthermore, its lines disappear in the diffraction pattern after annealing at 1073 K (Fig. 2d, Table 1).

The change of electric resistance *R* with temperature for the pellets listed in Table 1 is illustrated in Fig. 3. The temperature dependence of the as-compacted pellet was found to demonstrate semiconductor behavior similar to the Cu-13.1 % Mn-12.6 % Al alloy [4]. As is seen, its resistance decreases at temperatures above 120 K (Fig. 3a). By contrast, electric resistance of the pellet annealed at 1073 K clearly shows an opposite trend increasing with the temperature in the whole temperature interval of measurements. This is intrinsic to materials with metallic-type conductivity (Fig. 3c). Electric resistance of the pellet subjected to annealing at 873 K exhibits the behavior reflecting intermediate character of conductivity. Decreasing *R* within the temperature interval from 77 to 120 K is changed for its increasing above 180 K (Fig. 3b).



The variation of electric resistance for the compacted powders can be explained from results of X-ray phase analysis (Fig. 2, Table 1). It is evident that semiconducting character of conductivity is caused by the formation of copper oxide during ESD. Its content reduces due to decomposition as temperature of annealing is increased. These results are consistent with those [4] where semiconducting behavior associated with presence of copper and manganese oxides was reported for compacted specimens of highly dispersed Cu-13.1 % Mn-12.6 % Al powder. It should be noted that in case of disordered intermetallic alloys, semiconducting behavior can be attributed to strong atomic scattering, which results in quantum interference effects such as a weak localization or hopping conductivity [7–10]. Nevertheless, analysis of all collected experimental results allowed authors to conclude that the Cu-13.1 % Mn-12.6 % Al-compacted powders comprised of ordered and disordered phases demonstrated semiconducting behavior owing to appearance of oxide layer on the surface of particles rather than by other reasons [4]. Here, the compacted Cu powder specimens contain only copper and copper oxides without any disordered phase constituents. This and the other experimental data unambiguously confirm correlation between degree of oxidization of highly dispersed Cu particles and conduction mechanism.

As it follows from the X-ray diffraction data, thickness of oxide layers on the surface of Cu particles forming pellets is reduced with decreasing the content of Cu oxide in specimen and hence in particles. That is why, conductivity type depends on temperature of annealing. This contention is also supported by resistivity behavior at low-temperature characteristic of semiconductors in spite of only 2 % of Cu₂O in the specimen annealed at 873 K (Fig. 3b). If nanoparticles of Cu₂O had been distributed in the pellet regardless of Cu nanoparticles, resistivity of Cu₂O phase would never have effect on total resistivity being bridged by several orders lower resistivity of Cu. In fact, the measurements of R (Fig. 3b) show that below 120 K, semiconducting copper oxide phase dominates temperature behavior of resistivity and even at higher temperatures up to 180 K, there are no signs of prevalence of metallic type of conductivity associated with Cu phase. It is possible only if Cu₂O phase develops mainly on the surface of highly dispersed particles of Cu.

It is well known that resistivity of semiconductors exponentially decreases with the temperature due to enhancing the thermal activation, which excites electrons to the conduction band. In contrast, the resistivity of metals increases with the temperature following linear dependence at all temperatures except for low ones. The mixture of phases with different types of conductivity present in the alloy annealed at 873 K shows more complicated change of resistivity with the temperature. Switching observed between semiconductor and metallic

types of conductivity with the temperature (Fig. 3b) can be confirmed using Lichtenecker's formula for resistivity of two-phase alloys [11]:

$$\rho(T) = \rho_{\text{Cu}_2\text{O}}^c(T) \rho_{\text{Cu}}^{1-c}(T), \quad (1)$$

where $\rho_{\text{Cu}_2\text{O}}$ and ρ_{Cu} are the resistivities of copper oxide and pristine Cu, respectively, and c is the volume fraction of Cu₂O phase.

Without going into details of temperature dependence of resistivity over the whole temperature interval of the measurements, one can restrict the consideration to temperatures $T_S = 100$ K and $T_M = 273$ K, where respective semiconducting and metallic behavior of resistivity are well defined.

Let us estimate the ratio of $\rho(T)/\rho(T+\Delta T)$ (2) at T_S and T_M while $\Delta T = 1$ K. The value of this ratio will indicate the type of conductive mechanism at particular temperatures. Substitution of the expressions $\rho_{\text{Cu}_2\text{O}}(T) = A \exp\left(\frac{E_g}{2kT}\right)$ and $\rho_{\text{Cu}}(T + \Delta T) = \rho_{\text{Cu}}(T)(1 + \alpha\Delta T)$ where A is a constant, E_g is the energy gap in Cu₂O, α is the temperature coefficient of Cu resistivity into (1) and (2) yields

$$\begin{aligned} \frac{\rho(T)}{\rho(T+\Delta T)} &= \frac{\rho_{\text{Cu}_2\text{O}}^c(T) \rho_{\text{Cu}}^{1-c}(T)}{\rho_{\text{Cu}_2\text{O}}^c(T+\Delta T) \rho_{\text{Cu}}^{1-c}(T+\Delta T)} \\ &\approx \frac{\exp\left(\frac{cE_g\Delta T}{2kT^2}\right)}{(1+\alpha\Delta T)^{1-c}} \end{aligned}$$

Taking into account that $E_g = 2$ eV [12], $c = 0.02$, $\alpha = 0.004$, finally, we have

$$\frac{\rho(T_S)}{\rho(T_S+\Delta T)} \approx 1.02 > 1 \quad \text{and} \quad \frac{\rho(T_M)}{\rho(T_M+\Delta T)} \approx 0.99 < 1$$

This result suggests that at T_S , resistivity decreases while at T_M , it increases with the temperature in accordance with the experimental data (Fig. 2b).

Conclusions

Electric conductivity of compacted Cu powders prepared by ESD method and annealed in Ar environment varies with the annealing temperature as oxidation level of powder particles is changed. Appearance of semiconducting Cu₂O phase modifies metallic-type behavior of electric conductivity causing its growth with the temperature.

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Authors' Contributions

VN organized the whole work and wrote a draft of the manuscript; AP performed the XRD analysis and contributed to the manuscript drafting; VK supervised the work and revised the manuscript; SK finalized the manuscript,

conducted resistivity measurements, and estimated resistivity behavior of sample at different temperatures; TK performed the SEM observations. All authors read and approved the final manuscript.

Competing Interests

The authors declare that they have no competing interests.

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